

| Hits | Search Text | DBs |
|------|--|---|
| 11 1 | <p>((organic or polymer\$4 or polyimide or polyamide or photoresist or resist) same (conductive or electroconductive or semiconduct\$4 or transistor) same (dop\$4 or implant\$4 or infus\$3) same (irradiat\$4 or expos\$4 or illuminat\$4) same (UV or IR or DUV or EUV or excimer or laser or light or radiation)) and (step\$5 or (step\$4 near9 repeat) or (selectiv\$5 near12 expos\$4) or lithograph\$6 or irradiat\$4 or illuminat\$4) and (photomask or mask or reticle or pattern\$5) and ((dop\$4 or implant\$6) near22 (UV or irradiat\$4 or radiation or exops\$4)) and ((remov\$6 or etch\$6) same (weak or (less\$3 near16 (dop\$4 or implant\$4)) or unbound\$4 or non\$3bond\$4)) and (restor\$4 same conductiv\$4)</p> | US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB |

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| 12 | 181 | <p>((organic or polymer\$4 or polyimide or polyamide or photoresist or resist) same (conductive or electroconductive or semiconduct\$4 or transistor) same (dop\$4 or implant\$4 or infus\$3) same (irradiat\$4 or expos\$4 or illuminat\$4) same (UV or IR or DUV or EUV or excimer or laser or light or radiation)) and (step\$5 or (step\$4 near9 repeat) or (selectiv\$5 near12 expos\$4) or lithograph\$6 or irradiat\$4 or illuminat\$4) and (((dop\$4 or implant\$6 or infus\$4 or ions) near22 (UV or irradiat\$4 or radiation or expos\$4)) same (interconnect\$4 or ((organic or polymer\$3 or region) near19 (interconnect or connect\$4 or contact\$4))))</p> | US-PPGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB |

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| 13 | 75 | <p>((organic or polymer\$4 or polyimide or polyamide or photoresist or resist) same (conductive or electroconductive or semiconduct\$4 or transistor) same (dop\$4 or implant\$4 or infus\$3) same (irradiat\$4 or expos\$4 or illuminat\$4) same (UV or IR or DUV or EUV or excimer or laser or light or radiation)) and (step\$5 or (step\$4 near9 repeat) or (selectiv\$5 near12 expos\$4) or lithograph\$6 or irradiat\$4 or illuminat\$4) and (((dop\$4 or implant\$6 or infus\$4) near22 (UV or irradiat\$4 or radiation or expos\$4)) same (interconnect\$4 or ((organic or polymer\$3 or region) near19 (interconnect or connect\$4 or contact\$4))) same source same drain)</p> | US-PPGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB |
| 14 | 2 | JP-09083040-\$.did. | JPO; DERWENT |